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Citation: Journal of Applied Physics 78, 1992 (1995); doi: 10.1063/1.360173
View online: http://dx.doi.org/10.1063/1.360173
View Table of Contents: http://scitation.aip.org/content/aip/journal/jap/78/3?ver=pdfcov
Published by the AIP Publishing
Cathodoluminescence characterization of Ge-doped CdTe crystals

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(Received 8 December 1994; accepted for publication 11 April 1995)

Cathodoluminescence (CL) microscopic techniques have been used to study the spatial distribution of structural defects and the deep levels in CdTe:Ge bulk crystals. The effect of Ge doping with concentrations of $10^{17}$ and $10^{19}$ cm$^{-3}$ on the compensation of $V_{Cd}$ in CdTe has been investigated. Dependence of the intensity distribution of CL emission bands on the dopant concentration has been studied. Ge doping causes a substantial reduction of the generally referred to 1.40 eV luminescence, which is often present in undoped CdTe crystals, and enhances the 0.91 and 0.81 eV emissions. © 1995 American Institute of Physics.

INTRODUCTION

Recently, the doped CdTe bulk crystals have shown great promise for infrared optical processing application. The perspective of their practical usage puts forward several requirements to the crystals. In particular, a high room-temperature resistivity and a good photoconductivity on infrared irradiation are needed.

There exist few possibilities to get the CdTe crystals with the desirable properties by doping. These possibilities base themselves on the fact that in the undoped CdTe the main residual point defects are the shallow acceptors such as the background impurities of the group I (Li, Na, Cu, Ag) and their complexes with the native defects, mainly the vacancies of cadmium ($V_{Cd}$). For example, high-resistivity CdTe could be obtained by compensative doping with chlorine or gallium which are shallow donors in Te or Cd sublattices, respectively. However, doping with the impurities of V or IV groups, e.g., vanadium or germanium, can also provide the semi-insulating CdTe crystals by compensating deep donor levels.

It was demonstrated for the CdTe:V crystals by electron-paramagnetic-resonance (EPR) studies that the V impurity incorporates as an electrically and optically active defect into Cd sites, introducing a deep donor level at $E_D + 0.80$ eV. Recently, we have shown the drastic changes of CdTe luminescent properties related with V doping. Regarding to the Ge doping, which has some technological advantages, the Ge-related electronic levels have been studied by a few experimental methods such as photoconductivity, thermally stimulated conductivity, and the constant photocurrent method. Nevertheless, to our knowledge, there is no information about the influence of Ge doping on the luminescence properties of CdTe.

In the present investigation, semi-insulating CdTe:Ge with different Ge contents has been studied by cathodoluminescence (CL) with a scanning electron microscope. Differ-

EXPERIMENT

The CdTe bulk crystals used in the present investigation were grown by the vertical Bridgman technique at the experimental conditions specified elsewhere. The doping was done by introducing high-purity Ge into the ampoule. The calculated Ge concentrations in CdTe crystals were $10^{17}$ and $10^{19}$ cm$^{-3}$. Hereafter, we will call these crystals CdTe:Ge1 and CdTe:Ge2, respectively. The resistivity of both types of CdTe:Ge crystals was $10^{8}$–$10^{9}$ Ω cm at room temperature.

The monocrystalline wafers of about 20×10×1 mm$^3$ were cut from the central part of the grown crystals and polished by alumina powders, followed by a chemomechanical polishing with Br$_2$ (2 vol %)–methanol solution. Some of the as-grown wafers were annealed at 600 °C for 5 h under an Ar flux. To avoid annealing induced surface defects, the annealed wafers were polished again to remove about 50 μm from the surfaces.

The wafers were sliced and the samples obtained were observed in a Hitachi S-2500 scanning electron microscope in the emissive and CL modes at temperatures between 80 and 300 K with an accelerating voltage of 25 kV. The experimental setup for spectral and panchromatic CL measurements with a North Coast EO-817 germanium detector has been described elsewhere. In order to separate the contributions of the different bands in the CL images, monochromatic CL images are recorded at fixed wavelengths corresponding to the peak positions in the CL spectra. Spectra are recorded under different focusing conditions of the electron beam on the samples to account for the radiative centers with
FIG. 1. Panchromatic CL image of as-grown CdTe:Ge1.

low concentrations. Usually by defocusing, the intensity of deep level bands increases. In the following description, spectra showing deep level emissions have been recorded with a defocused electron beam.

RESULT

Figure 1 shows a typical panchromatic CL image of the as-grown CdTe:Ge1 sample. Bright sub-boundaries with a certain structure and bright spots inside the subgrains are revealed. Similar images were also observed in case of our previously studied CdTe:V samples. The CL spectrum of CdTe:Ge1 samples at 80 K obtained under defocusing conditions is given in Fig. 2(a). Neither the band-edge peak nor the generally referred to $1.40 \text{ eV}$ peak were clearly revealed. However, those two bands were revealed, though with a very low intensity, in the as-grown CdTe:Ge2 samples by defocusing the electron beam [Fig. 2(b)]. Also, an intense band at about $0.91 \text{ eV}$ and a very weak band near $1.08 \text{ eV}$ appeared along with the $0.81 \text{ eV}$ band. It is observed in Fig. 2 that the $0.81 \text{ eV}$ band appears more intense in the sample with a higher Ge concentration. Under the focused electron-beam condition, in all the doped samples, the total CL intensity was low and only a peak near $0.81 \text{ eV}$ was revealed.

Figure 3 shows the CL spectra of the CdTe:Ge samples after annealing. No band-edge peak or the $1.40 \text{ eV}$ peak appeared under any of the electron-beam conditions. However, both the $0.91$ and $0.81 \text{ eV}$ bands appeared under both electron-beam conditions. There are at least four bands in the $0.72-1.10 \text{ eV}$ energy range, with at least two sub-bands each, which have often been detected in CdTe crystals by other workers in their photoluminescence studies. From the shape of the $0.91 \text{ eV}$ band in our CL spectra, it appears that the band has a complex structure. In some cases, the $0.78 \text{ eV}$ band was resolved from the $0.81 \text{ eV}$ band. In the annealed samples the intensity of the $0.81 \text{ eV}$ band increases with Ge concentration (Fig. 3), which is a similar behavior to that found in the as-grown samples. Figure 4 shows the panchromatic CL image of an annealed CdTe:Ge1 sample at 80 K. By annealing, the sharper sub-boundaries become blurred and the contrast is drastically reduced. Monochromatic images recorded with the monochromator slit at 0.90 or 0.80 eV exhibit the same general luminescence distribution as that shown in Fig. 4. The general appearance of the image from

FIG. 2. CL spectra recorded under defocusing conditions of as-grown samples: (a) CdTe:Ge1 and (b) CdTe:Ge2.

FIG. 3. CL spectra recorded under defocusing conditions of as-grown samples: (a) CdTe:Ge1 and (b) CdTe:Ge2.

DISCUSSION

Undoped samples show near band-edge emission as well as a band at $1.40 \text{ eV}$ while both bands are generally absent in Ge-doped samples. The $1.40 \text{ eV}$ band in CdTe has a complex nature with a component, which in some cases determines the appearance of the band, due to $A$ centers (cadmium vacancy—donor pairs). This component explains the absence or reduction of $1.40 \text{ eV}$ emission in Ge-doped samples be-
cause a Ge impurity situated in Cd sites reduces the $V_{\text{Cd}}$ concentration and consequently decreases the probability of A-center formation. A similar effect has been previously observed in the V-doped samples\(^8\) while In doping enhances the A-center component.\(^{16}\) The similarity of ionic radius of Cd(0.97 Å) and Ge (0.93 Å) would favor the filling of $V_{\text{Cd}}$ by Ge as compared with other impurities with a higher radius. The latter tend to form complexes with $V_{\text{Cd}}$ rather than fill these vacancies. On the other hand, doping with atoms occupying Te sites in CdTe does not inhibit the appearance of the 1.40 eV band.\(^{17}\) The appearance of a band-edge peak and the 1.40 eV peak with a very low intensity in the CdTe:Ge2 samples may be due to the difference in the residual defect distribution in the crystals during the different growth runs.

In the low-energy region of the spectra, two bands centered, respectively, at about 0.91 and 0.81 eV are observed in both doped and undoped samples. The bands are more intense in doped samples, suggesting the influence of Ge atoms. In particular, the 0.81 eV band is always revealed as an intense emission in the spectra of doped samples while in undoped material is clearly revealed only under specific excitation conditions (defocused electron beam). The influence of Ge on the 0.81 eV band is also apparent in its higher intensity in the CdTe:Ge2 crystals. The luminescence of CdTe in the 0.81 eV region has been found to consist of two overlapping sub-bands with maxima at 0.81 and 0.72 eV, respectively.\(^{14,15}\) Takebe et al.\(^{18}\) characterized deep levels in CdTe by a photocapacitance technique and deep level transient spectroscopy and concluded that a center that can emit photons of 0.75 eV includes Cd vacancies or an impurity, as Si in Cd sites, whose solubility or stable site in the lattice depends on Cd vapor pressure. Emission in the 0.81 eV region in our undoped samples could be due, according with the results of Ref. 17, to the Si residual impurity in CdTe. The observed enhancement of the 0.81 eV band in the Ge-doped samples can be explained by the fact that Ge plays a similar role as Si in the 0.81 eV emission. The band peaked at about 0.91 eV which is present in both kinds of samples but more readily observed in Ge-doped crystals, can have a similar origin as the 0.81 eV emission. In a study of deep levels in CdTe by EPR techniques\(^{19}\) a level at 0.95 eV below the conduction-band edge was assigned to Ge dopant.

CL images show that centers emitting in the 0.70–0.91 eV range, which are responsible for the luminescence in Ge-doped samples, are preferentially distributed in the sub-boundaries. The grainy structure of sub-boundaries in the CL images has been observed in other doped CdTe crystals\(^8\) and indicates an inhomogeneous distribution of luminescence.
centers along the sub-boundaries. However, on increasing the Ge atom concentration, these centers become more concentrated at the sub-boundaries.

The results of annealing treatment support the possibility that Ge is involved in the emission at 0.91 and 0.81 eV. Annealing the undoped samples causes the increase of a band at 1.08 eV and the suppression of emission at lower energies. This 1.08 eV band has previously been reported in annealed undoped CdTe and is attributed to the presence of Te vacancies. Annealing the Ge-doped samples causes the increase of the 0.81 and 0.91 eV bands as depicted in Fig. 3. During annealing, cadmium vacancies are generated and the probability of formation of complex centers involving Ge in Cd sites is enhanced. The diffuse appearance of luminescence in CL images of annealed samples indicates the redistribution and formation of luminescent centers during annealing related to vacancy generation and impurity diffusion processes.

CONCLUSIONS

Like V atoms, Ge plays a similar role of compensating Cd vacancies and reduces the probability of A-center formation in CdTe crystals. Appearance of 0.81 eV emission in CdTe crystals can be influenced very much by Ge doping. Postgrowth thermal annealing of the Ge-doped CdTe causes the formation of Cd and Te vacancies and enhances the probability of formation of complex centers involving Ge in Cd sites.

In undoped CdTe, either annealed or unannealed, the contribution of 0.91 and 0.81 eV emission is minor to the total luminescence integrated intensity. On the contrary, in Ge-doped CdTe crystals those levels are a much more important radiative pathway because the near-band-gap radiative transitions are greatly reduced.

ACKNOWLEDGMENTS

Two of the authors (U. P. and N. V. S.) thank Spanish MEC for the postdoctoral research grants. The work has been supported by the DGICYT (PB90-1017 and PB93-1256) projects.